## Analizing GF180 process Manual for ESD design.

- Using regular devices data to construct the ESD window.
  - Oxide Breakdowns.
  - NMOS max operation voltages.
  - PMOS max operation voltages.
  - Look at Chapter 5 on the following Link. GF180MCU process Manual.
  - <a href="https://gf180mcu-pdk.readthedocs.io/en/latest/physical-verification/design-manual/drm-15.html">https://gf180mcu-pdk.readthedocs.io/en/latest/physical-verification/design-manual/drm-15.html</a>
- Understanding ESD special devices.
- Understanding TLP data for each of them.
  - Sizing the devices correctly.
  - Look for Chapter 14 for GF180MCU process manual.
  - https://gf180mcupdk.readthedocs.io/en/latest/physical verification/design manual/drm 14. html

## Real World Exercise:

- Use GF180 Manual Specs.
- Our Chip is a 5 pin part. VCC, GND, IO1, IO2, IO3.
  - VCC is 3V +/- 10%. 100uA ICC consumption. Max reverse rating = -0.5V.
  - IO1 is Digital, Push Pull inverter Outputs. +/- 1mA, 100mV (100ohm).
  - IO2 is a GATE INPUT pin. 3V rated. +/-100nA current.
  - IO3 is an OPEN Drain Nmos Output. +1mA, 100mV, 5V rated. (100ohm).
  - Need to Pass 2Kv HBM spec for all Pins expect IO3 that must pass 4Kv.
- Draw the PAD RING equivalent Circuit and define an ESD Protection Architecture using a Power Clamp + Local Protections.
- Calculate the ESD window for a VCC-GND discharge.
  - Digital Circuits Gates connected between VCC-GND.
- Describe the Current Path for ESD event IF no protection is given.
- Propose a Power Clamp for it.
  - Draw the Characteristic over the ESD Window graph.
  - Consider effect of Metallization.
  - Define the Star-VCC and Star-GND concept Nodes.

## Exercise 2:

- Consider IO1 now.
  - Analize Events to GND. Positive and Negative.
  - Analize Events to VCC. Positive and Negative.
  - Draw the ESD Window.
  - Consider an Architecture that will Share the Power Clamp on VCC-GND.
    - Draw the current path during ESD events IF protection is NOT place.
    - Same when protection is connected.
    - Consider effects of metallization.
- Consider IO2 now.

## Exercise 3:

- Consider I03 to GND now.
  - Draw the ESD window.
    - Figure the Current path for ESD event if No protection is available.
  - Find a ESD protection Solution:
    - A) Using an Isolated Protection.
      - Estimate the Size for the Protection.
      - Figure the Current Path during en ESD event.
    - B) Reusing the Power Clamp located in VCC-GND.
      - Figure the current path during ESD event.
      - Estimate the Size for the Local device.
      - Consider the effect of metallization.
    - C) Compare and discuss A) and B).
- Repeat for IO3 to VCC case.
- Discuss the 6 steps of ESD design Methodology.
- Discuss the usage of TLP measurements to verify the circuitry design.